Prediction of 2D IV-V semiconductors: Flexible monolayers with

tunable bandgap and strong optical absorption as water-splitting

photocatalysts

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Fig. S1 The phonon spectra (a-c), Energy fluctuations in AIMD simulations at 300 K (d-f), HSE06 band structures and the corresponding partial density of states (g-i) of SiSb₂, GeSb₂ and SnSb₂ monolayers. The insets in (d-f) are the snapshots taken from the end of each simulation.

Table S1. Elastic constants (in Jm⁻²), Young's modulus (Y, in Jm⁻²), and Poisson's ratio (v) of XY₂ sheets. The reported data for pentagonal CP₂, CAs₂, CSb₂ and GeP₂ are included for comparison.

XY ₂	$C_{11} = C_{22}$	C_{12}	C_{66}	Y	V
SiSb ₂	30.97	11.45	21.20	42.42	0.37
GeAs ₂	38.51	10.19	23.26	35.82	0.26
GeSb ₂	27.11	9.63	18.13	36.50	0.36
SnP ₂	37.48	7.60	20.14	35.94	0.20
SnAs ₂	29.99	8.31	16.84	27.69	0.28
$SnSb_2$	22.13	7.56	13.20	19.54	0.34
$CP_{2}^{[5]}$	84.11	44.72	79.18	60.33	0.53
$CAs_2^{[5]}$	63.77	41.07	61.46	37.32	0.64
$CSb_2^{[5]}$	40.78	36.20	44.94	8.65	0.89
$GeP_{2}^{[6]}$	47.41	9.42	16.88	45.53	0.20



Fig. S2 The partial density of states (PDOS) of GeAs₂ (a), SnP₂ (b), and SnAs₂ (c).



Fig. S3 The spatial charge density of VBM and CBM of the pentagonal GeAs₂ (a), SnP₂ (b), and SnAs₂ (c). The isolevels are set to be 0.004 $e^{A^{-3}}$.



Fig. S4 Energy fluctuations for strained monolayers $GeAs_2$ (a), SnP_2 (b), and $SnAs_2$ (c) by MD simulations at 300 K. The insets are the snapshots taken from the end of each simulation.



Fig. S5 (a-j) Band structure of GeAs₂ under different biaxial strains.



Fig. S6 (a-j) Band structure of SnP₂ under different biaxial strains.



Fig. S7 (a-j) Band structure of $SnAs_2$ under different biaxial strains.

References

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